Two-dimensional electron-gas actuation and transduction for GaAs nanoelectromechanical systems

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We have fabricated doubly clamped beams from GaAs/AlGaAs quantum-well heterostructures containing a high-mobility two-dimensional electron gas (2DEG). Applying an rf drive to in-plane side gates excites the beam’s mechanical resonance through a dipole–dipole mechanism. Sensitive high-frequency displacement transduction is achieved by measuring the ac emf developed across the 2DEG in the presence of a constant dc sense current. The high mobility of the incorporated 2DEG provides low-noise, low-power, and high-gain electromechanical displacement sensing through combined piezoelectric and piezoresistive mechanisms. © 2002 American Institute of Physics. [DOI: 10.1063/1.1516237]

Thin, suspended two-dimensional electron gas (2DEG) heterostructures have been recently perfected, and have subsequently been employed for nanoscale conducting devices. In this letter, we present a high-resolution displacement readout that is based upon our ability to achieve very high mobility suspended quantum wires. Molecular beam epitaxial (MBE) grown materials are directly patterned and in-plane gates are used to excite the vibration. No metallization is needed, hence high Q values can be obtained.

The starting material was a specially designed, MBE-grown, 2DEG heterostructure similar to that used in Ref. 1. The structural layer stack comprises seven individual layers having a total thickness of 115 nm. The top and bottom are thin GaAs cap layers preventing oxidation of the Al0.3Ga0.7As:Si donor layers in between. The central 10-nm-thick GaAs layer forms a quantum well sustaining a high mobility 2DEG located 37 nm below the top surface and surrounded by two AlGaAs spacer layers. Below the structural layer stack is a 400 nm Al0.5Ga0.5As sacrificial layer. The structure was intentionally made asymmetric to avoid neutralizing the piezoelectric effect of GaAs.

After ohmic contacts were deposited, a thick layer of poly-methyl-methacrylate (PMMA) is spun on the chip, followed by a single electron-beam lithography step to expose trenches in PMMA that isolate the beam from its side gates. PMMA was then employed as a direct mask against a low voltage electron cyclotron reactor etch performed to further etch the trenches to the sacrificial layer. After stripping off the PMMA, final structure relief is achieved by removing the sacrificial layer beneath the beams with diluted HF. To minimize the damage to the 2DEG from dry etching, a Cl2/He plasma was chosen because of its excellent etching characteristics, such as smooth surface morphology and vertical sidewall. A stable etching speed at 35 Å/s is obtained under conditions of less than 150 V self-bias (20 W constant rf power), Cl2 and He flow rate ratio 1:9, 3 mTorr pressure, and 300 W microwave power. With the same method, we have also fabricated suspended Hall bars and extensively characterized the resulting suspended 2DEG. Before processing, the initial mobility and density after illumination are $5.1 \times 10^5$ cm²/Vs, $1.26 \times 10^{12}$ cm⁻², respectively. With our improved low damage etching, the mobility can be maintained at $2.0 \times 10^5$ cm²/Vs, while the electron density is somewhat reduced to $4.5 \times 10^{11}$ cm⁻². We observed well-developed quantum Hall plateaus in the etched structure even with channel width as small as 0.35 μm. In longitudinal resistance measurements, we detected a low field maximum, corresponding to maximal boundary scattering when the electron cyclotron motion diameter matches the electrical width of the suspended wire. From the position of this peak, we are able to deduce the depletion to be 0.1 μm on each side of the wire. We also confirmed ballistic behavior of electrons from transport measurement on the Hall cross-junction. Both “last Hall plateau” and “negative bendresistance” are present in all of the devices. The transport mean free path was found to be approximately 2 μm.

A typical device is shown in Fig. 1. The beams are 0.5 μm wide and 6 μm long, having a calculated spring constant of 0.25 N/m. When cooled to liquid helium temperature, their two-terminal resistance is about 100 kΩ. After illumination, this drops to about 5 kΩ (including contact and lead resistances). The electrical width of the beam is about 0.3 μm with $R_\text{env} = 170$ Ω.

In nanoelectromechanical system (NEMS), both the induction and the detection of motion pose important challenges. In our devices, the actuation is relatively trivial and very effective. The rf drive is supplied directly to one of the side gates, which is a large area of 2DEG connected to the output of a network analyzer through alloyed ohmic contact. All the trenches have a width of 0.5 μm. The devices are first measured at 4.2 K in vacuum. A constant dc sensing current ranging from 0 to 26 μA is supplied to the vibrating beam through a 10 mH rf choke, whose value is chosen large...
enough to avoid loss of the small signal that is induced. The oscillatory signal is picked up by a low temperature amplifier placed in close proximity to the device. Before connecting the signal to the input of the network analyzer, a room temperature amplifier is used to improve signal-to-noise ratio.

The combined amplifiers have a voltage gain of about 200 in the frequency range of these experiments.

We observed a very strong signal around the first mechanical resonance. The magnitude response curves at various driving amplitudes are shown in Fig. 2(a). Calculations confirm this resonance corresponds to the first out-of-plane vibrational mode. When the drive amplitude is increased above 45 mV, the response curve becomes nonlinear and assumes an asymmetric shape. In the linear response region, the amplitude at resonance is proportional to the ac gate voltage amplitude.

To clarify the origin of the observed signal, we fixed the drive at 10 mV and then varied the dc bias current from −26 μA to 0 and then to 26 μA. The response amplitude versus drive amplitude at resonance is presented in Fig. 2(b). Two features are evident from this data. First, at the highest currents close to 20 μA, the signal becomes saturated for two reasons: (a) Joule heating of the small beam, and (b) saturation of the drift velocity at high applied electrical fields (~15 kV/m). Second, at intermediate current the signal strength at resonance is proportional to the dc bias current, as indicated in the inset of Fig. 2(b). In addition, when we reverse the current direction, we also find that the induced signal changes its sign (180° phase change). Therefore, we conclude that the dominant contribution to the observed signal is a change of resistance due to beam vibration. This appears to originate from both piezoresistive effect of bulk GaAs and transverse piezoelectric charge gating of 2DEG.

Note that in Fig. 2, all the driving force results from the applied ac gate voltage. We did not find any significant change of resonant frequency or magnitude with dc bias on the gate. This is indicative of a coupling mechanism different from electrostatic force between the gates and the beam. Electrostatic force is proportional to the product of dc and ac components of gate potential so that the response should directly scale with the dc gate voltage. This assumes a direct Coulomb interaction between coupling plates. In our in-plane-gate configuration, the net charge on the beam is given by $Q = e(1 - \nu^2)$, where $e$ is the electric field intensity, $\nu$ is Poisson’s ratio for GaAs, and $\nu = 0.31$, we obtain $x_c = 6 \text{ nm}$, which is attained at a drive level of about 45 mV. The minimum resolvable signal is achieved at 0.1 mV drive and about 5 μA sensing current. Hence, at the highest possible current of 20 μA, we can detect a resonance at $x_c = 450/4 = 0.03 \text{ Å}$, or 3 × 10⁻³ Å/Hz, which is consistent with our estimate based on Johnson noise from beam resistance at 4.2 K. The corresponding force sensitivity is 75 fN/Hz, comparable with previous schemes to detect small NEMS resonators by optical interferometry and the magnetomotive method. The required force to drive the beam to the nonlinearity threshold is 1.5 nN. The displacement resolution can be improved by using 2DEG heterostructures with even higher mobility, or by operating at ~100 mK with a state-of-the-art low temperature preamplifier.

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applied on the gate is $(V_g^{(0)} + v_s e^{i\omega t})/d$, $d$ is the beam–gate separation (Fig. 3). Thus, the total electrostatic force applied on the beam with angular frequency $\omega$ is $f = CV_g^{(0)}v_se^{i\omega t}/d$. Only a projection of this force drives the beam along the out-of-plane ($y$) direction. A reasonable estimate of the effective $y$-component of this force is

$$f_y = CV_g^{(0)}v_se^{i\omega t}y/d^2,$$

(1)

where $y_0$ is a static offset due to, for example, uncontrolled asymmetry of suspended beam. A 10 nm misalignment of the beam with respect to gate should be observable in our devices (but is not seen). Therefore, we take this number as the upper limit in our estimation of $y_0$. At a nominal 1 V dc gate voltage, 45 mV ac gate voltage, the force originating from the electrostatic drive mechanism is calculated to be $f_y = 0.2$ pN. This is four orders of magnitude smaller than the direct Coulomb interaction. This dipole–dipole interaction potential can be estimated to be 1.2 nN from this mechanism, four orders of magnitude higher than the direct Coulomb interaction. This dipole–dipole interaction is unique to NEMS and is insignificant in microelectromechanical systems.

We have also studied the temperature dependence of our strain sensitive devices. Measurements were performed at three different temperatures in vacuum. The results are shown in Fig. 4. The devices perform exceptionally well at liquid helium and nitrogen temperatures, but at room temperature, the response is diminished. The decay of signal strength with temperature can be attributed to the significant reduction of 2DEG mobility. At elevated temperature the increased two-terminal beam resistance acts as a large voltage divider, and only a small fraction of induced signal voltage is available.

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